

PATENT

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of:

Wang Yueh, et al.

Application No.: 10/750,042

Filed: December 30, 2003

For: A LOW OUTGASSING AND NON-
CROSSLINKING SERIES OF POLYMERS FOR
EUV NEGATIVE TONE PHOTORESISTS

Examiner: Amanda C. Walke

Art Unit: 1795

Confirmation No.: 9165

Mail Stop Amendment

Commissioner For Patents

P.O. Box 1450

Alexandria, VA 22313-1450

RESPONSE TO OFFICE ACTION

In response to the Office Action mailed January 7, 2008, Applicant respectfully requests reconsideration of the above-identified patent application in light of the following.

Amendments to the Claims are reflected in the listing of claims which begins on page 2 of this paper.

Remarks/Arguments begin on page 8 of this paper.

Conclusion begins on page 10 of this paper.

Filed via EFS Web: May 7, 2008